

AMENDMENTS TO THE SPECIFICATION

The paragraph beginning on page 1, line 16, is being amended as follows:

A variety of processes for producing such color filter ~~array~~ arrays have been proposed. Among them, a so-called "color resist method" is in wide practical use. In the color resist method, the patterning is effected by exposing a photosensitive resin composition comprising colorants to light and developing, and the patterning is repeated in sequence in the required times.

The paragraph beginning on page 3, line 11, is being amended as follows:

A colorant exhibiting a small absorption of visible ray and near ultra violet ray. However, generally colorants exhibiting a small absorption of visible ray and near ultra violet ray is not satisfactory in light fastness. Further, such a dye has low solubility in a photosensitive resin composition, and a photosensitive resin composition containing the dye at a high concentration cannot be easily obtained ~~easily~~.

The paragraph beginning on page 10, line 9, is being amended as follows:

Examples of the hydroxyalkyl group having 1 to 4 carbon atoms include ~~hydroxymethyl~~ hydroxymethyl group, hydroxyethyl group, hydroxypropyl group, and hydroxybutyl group. Examples of the alkyl group having 1 to 4 carbon atoms and substituted with an alkoxy group having 1 to 4 carbon atoms include methoxymethyl group, methoxyethyl group, ethoxyethyl group, and propoxybutyl group.